

# Magnetic pinning in hybrid $\text{YBa}_2\text{Cu}_3\text{O}_{7-x}$ /ferromagnetic nano-dot structures obtained by di-block copolymer self-assembly method



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**UNIVERSITATEA TEHNICĂ**  
DIN CLUJ-NAPOCA



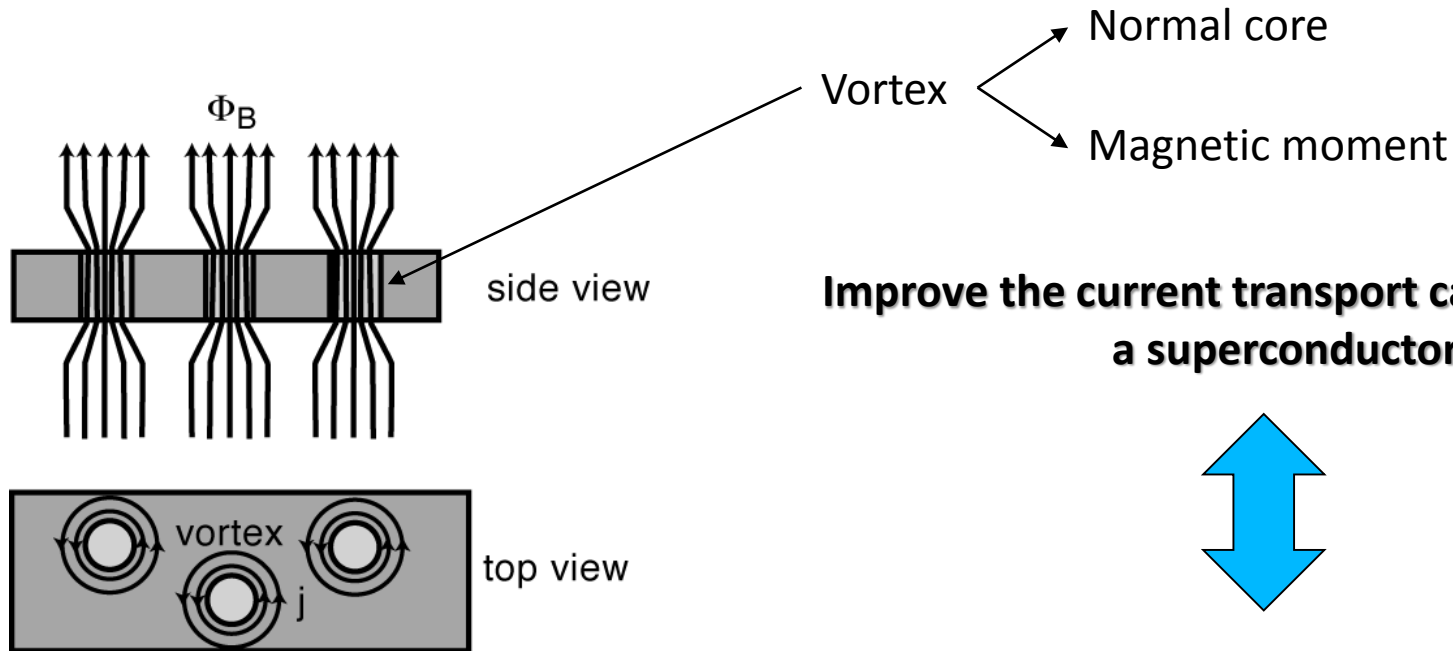
**Magpin**

*Nano-engineered Magnetic Pinning Centers in High Temperature Superconducting Epitaxial Thin Films - MAGPIN*

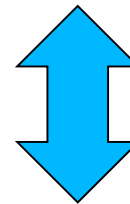
PNII – RU – TE – 2014 - 2848

# The challenge of vortex pinning in type II superconductors

- Maximum current density carried by a superconductor (type II) is limited by the motion of **vortices**

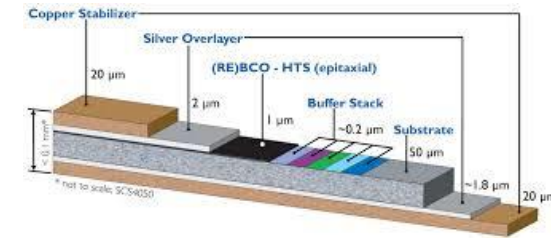


Improve the current transport capabilities of a superconductor

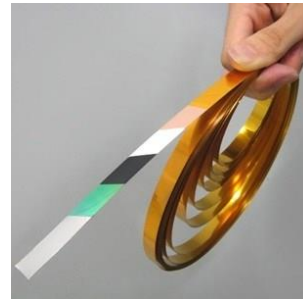


Stop vortex motion

**VORTEX PINNING**



SuperPower Inc.

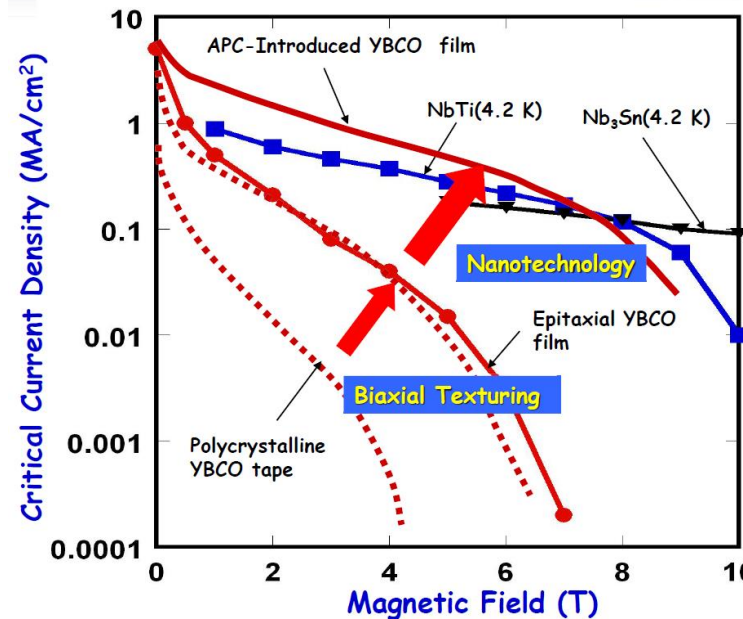
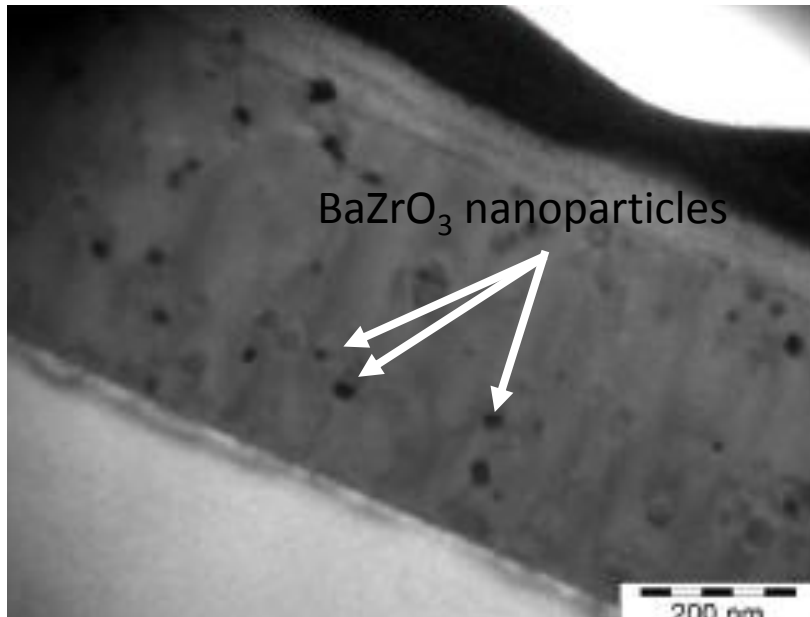
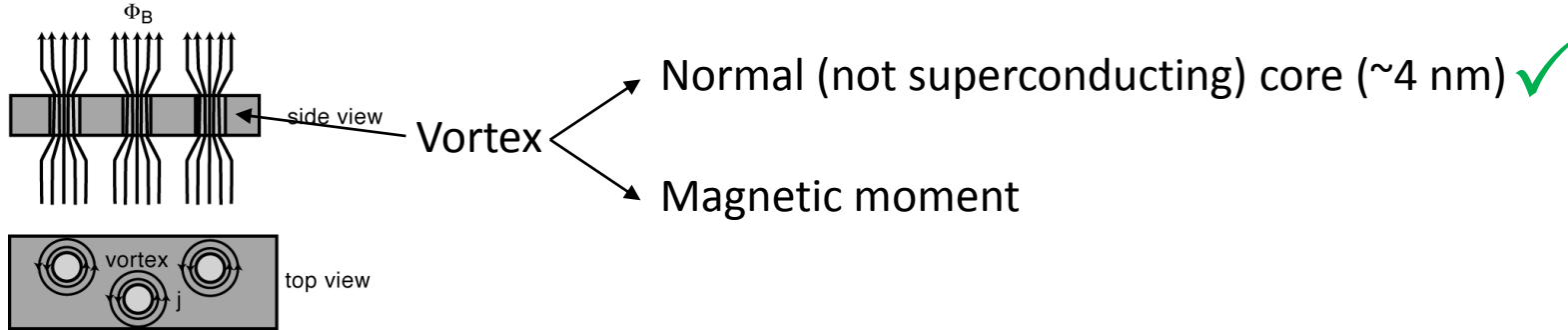


Fujikura Ltd.

<http://users-phys.au.dk/philip/pictures/physicsfigures/node12.html>

# The challenge of vortex pinning in type II superconductors

## Stop vortex motion (vortex pinning)



## Normal core pinning

- introduction of non-superconducting (e.g. BaZrO<sub>3</sub>) nanoparticles;
- achieved and used at an industrial level;
- Pinning energy:

$$U_{cp} \approx \left[ \Phi_0 / 8\pi\lambda(T) \right]^2$$

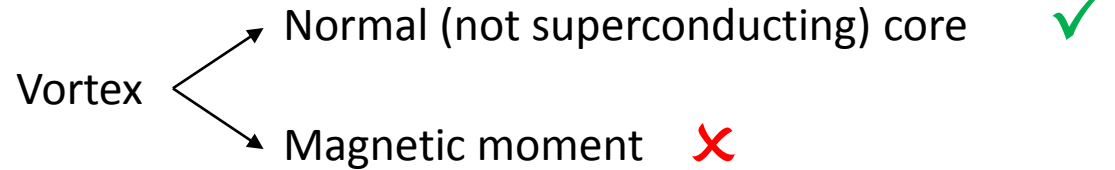
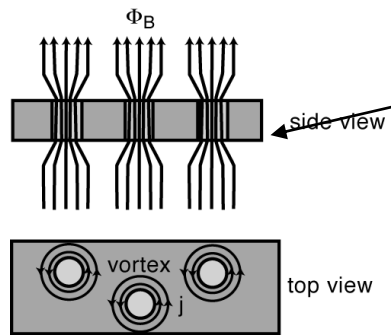
decreases as  $T \rightarrow T_c$  due to

$$\lambda^2(T) / \lambda^2(0) \approx (1 - T/T_c)^{-1}$$

**Normal core pinning becomes ineffective near  $T_c$  (working temperature)**

# The challenge of vortex pinning in type II superconductors

## Stop vortex motion (vortex pinning)



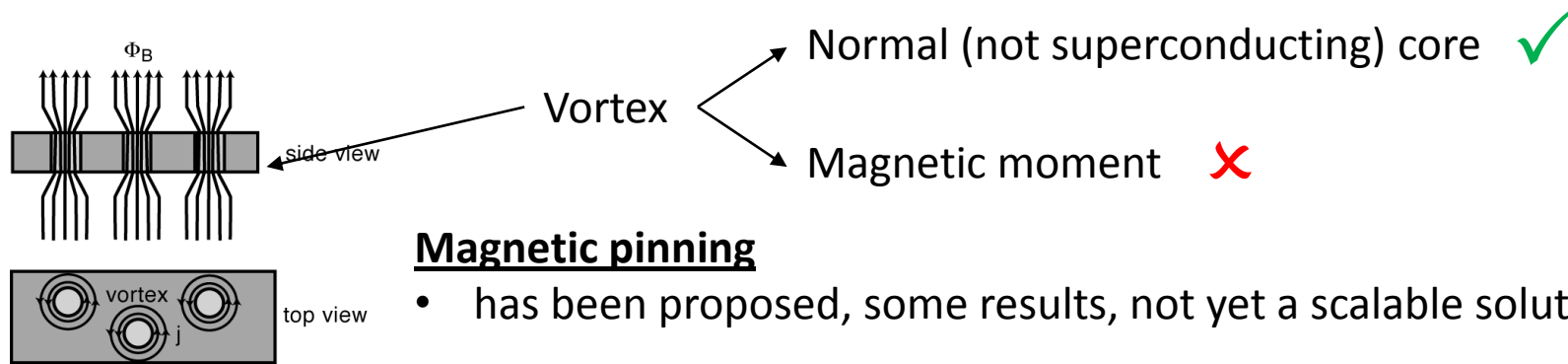
### Magnetic pinning

- has been proposed, some results, not yet a scalable solution;
- magnetic pinning energy:  $U_{mp} \approx \Phi_0 M$  (M-magnetization of the ferromagnetic layer/particle);
- magnetic pinning force:  $F_{mp} \approx -\Phi_0 \partial M(x) / \partial x$  needs high magnetization gradient use of **domain walls** and/or **magnetic nanoparticles**;
- **temperature independent**, effective near  $T_c$  (**high** temperature superconductors)

Objectives of the present project: Explore alternative, scalable routes for producing effective magnetic vortex pinning in superconducting thin films

# The challenge of vortex pinning in type II superconductors

## Stop vortex motion (vortex pinning)

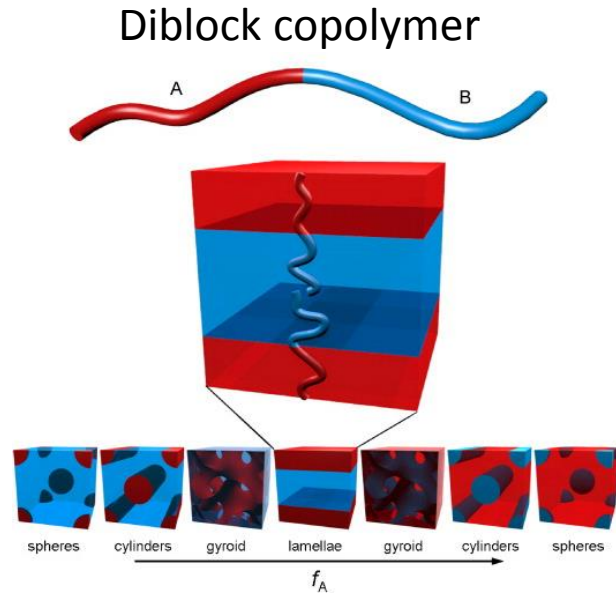


### Magnetic pinning

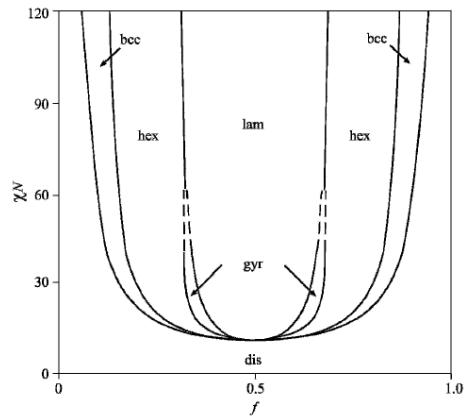
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**Objectives of the present project: Explore alternative, scalable routes for producing effective magnetic vortex pinning in superconducting thin films**

# Micro-phase separation of diblock copolymer thin films

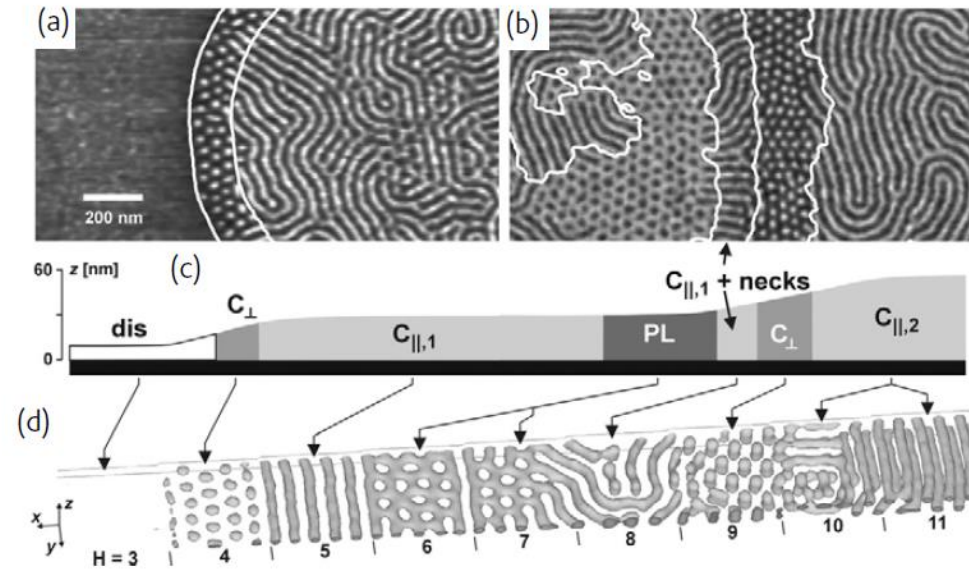


S. B. Darling, *Progress in Polymer Science* **32**, 1152 (2007)



I. W. Hamley, *Developments in Block Copolymer Science and Technology*, Wiley (2004)

Block copolymer thin film morphology variation as a function of film thickness



S. Krishnamoorthy *et al.*, *Materials Today* **9**, 40 (2006)

# Micro-phase separation of diblock copolymer thin films

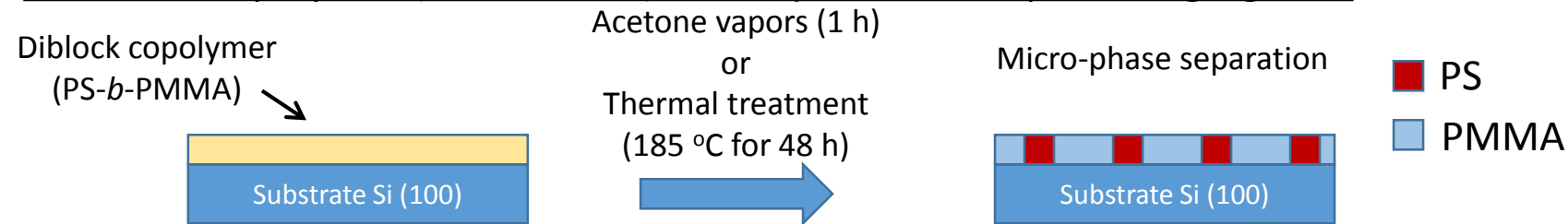
## Diblock copolymer nanostructure fabrication

### Poly (Styrene-block-Methyl Methacrylate)

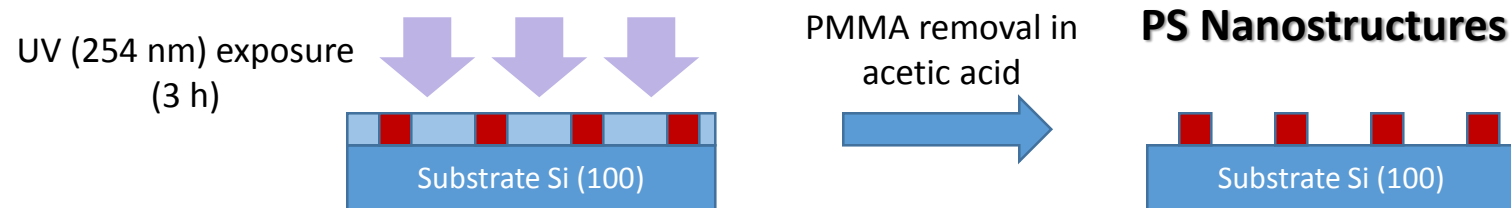
30% PS  70% PMMA

PS-*b*-PMMA  
63.000-*b*-142.000  
 $c=3$  mg/ml  
(solvent-toluene)

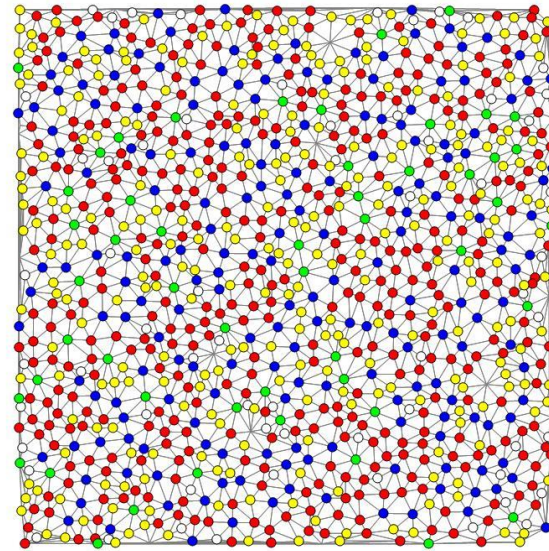
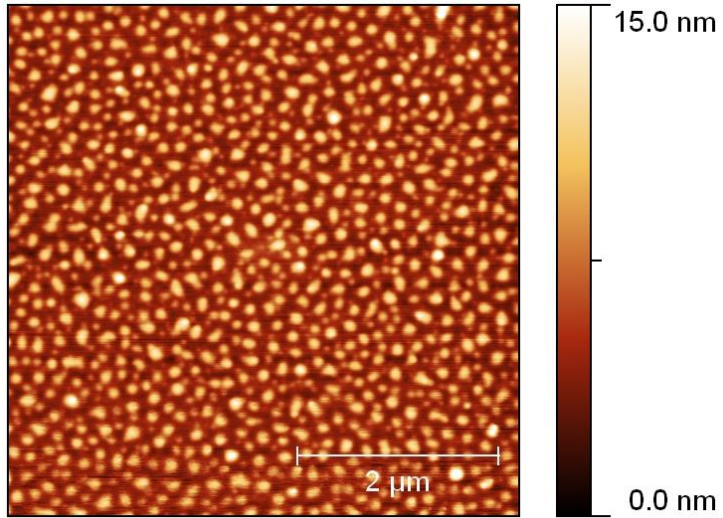
### 1. Diblock copolymer (PS-*b*-PMMA) film deposition and phase segregation



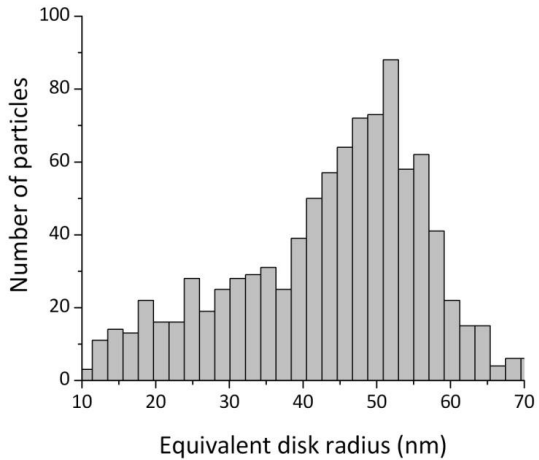
### 2. PMMA matrix UV degradation and removal



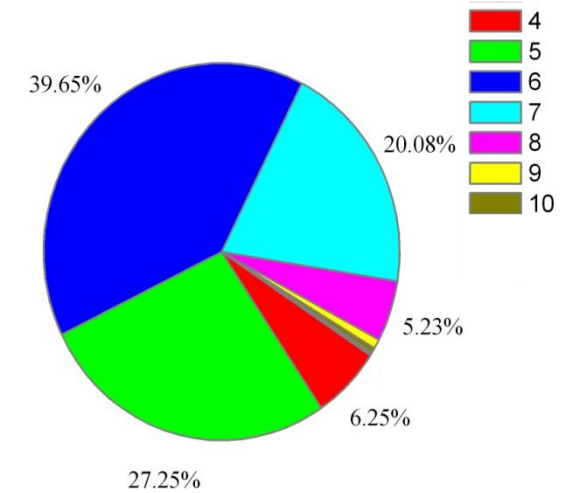
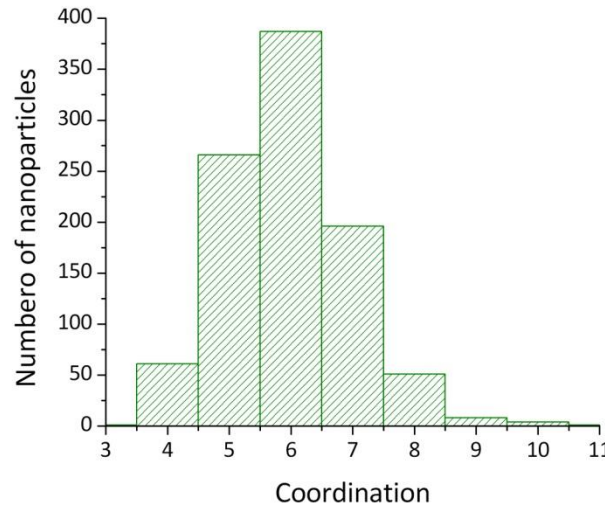
# Poly-styrene nano-dot morphology



## Delaunay Triangulation – Nanoparticle coordination



**Nanoparticle radius**  
distribution centered **~50 nm**,  
**Height = 5 nm**

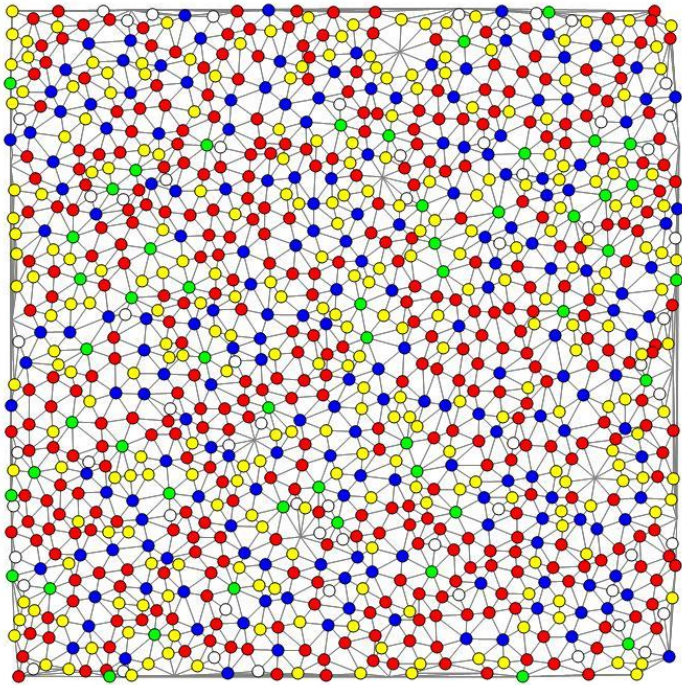




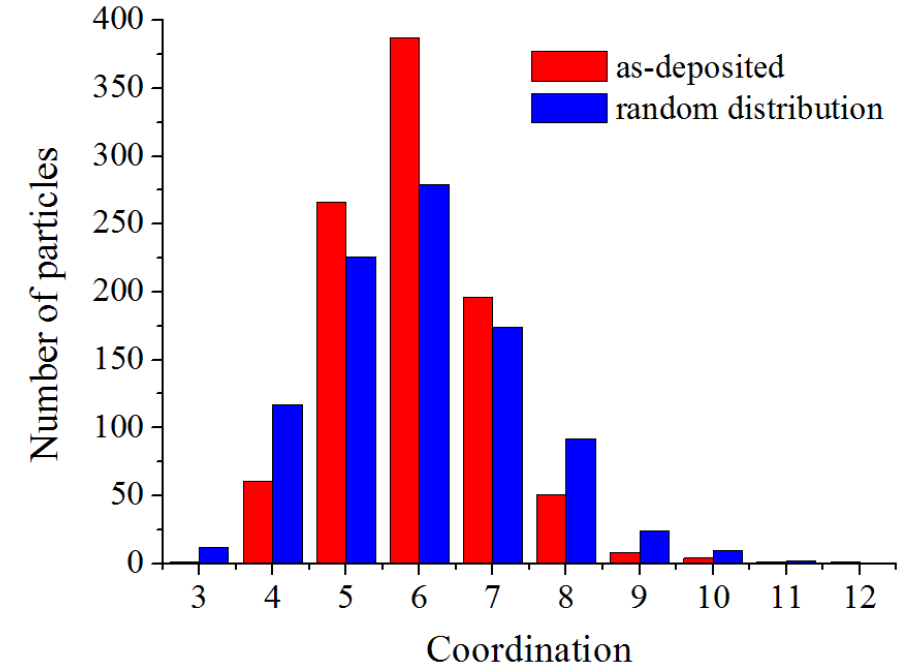
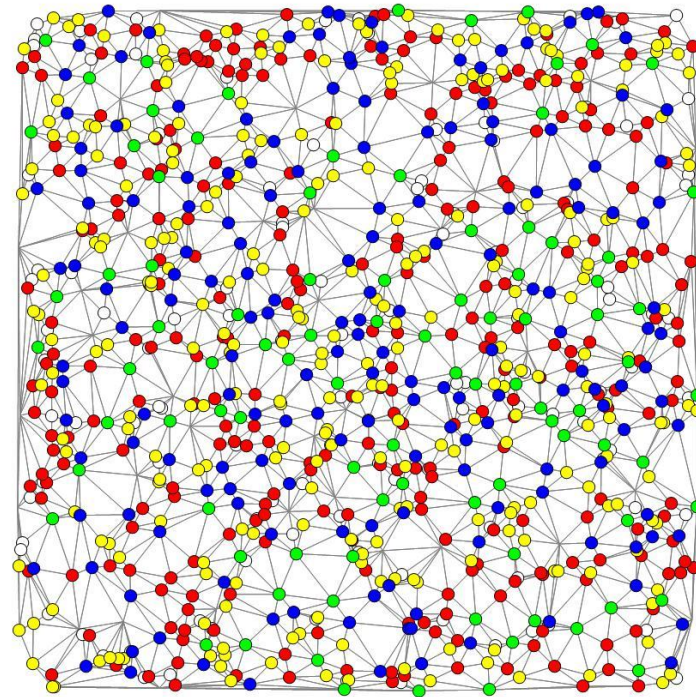
# Poly-styrene nano-dot morphology

## Delaunay Triangulation – Nanoparticle coordination

as-obtained nanodots



simulated random distribution

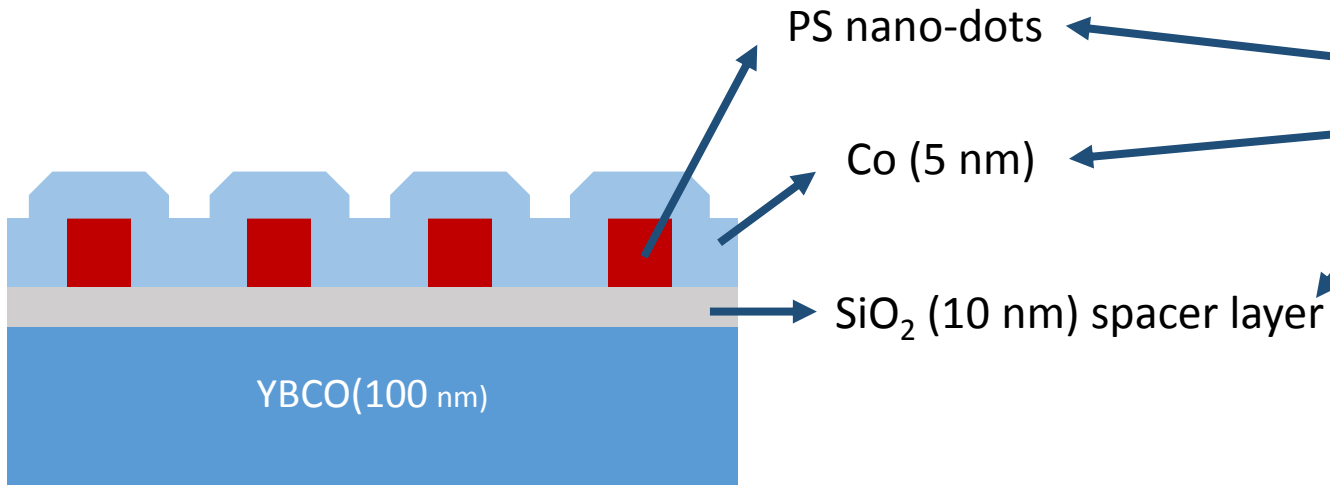


Random, but highly uniform, distribution of PS nano-dots on substrate surface

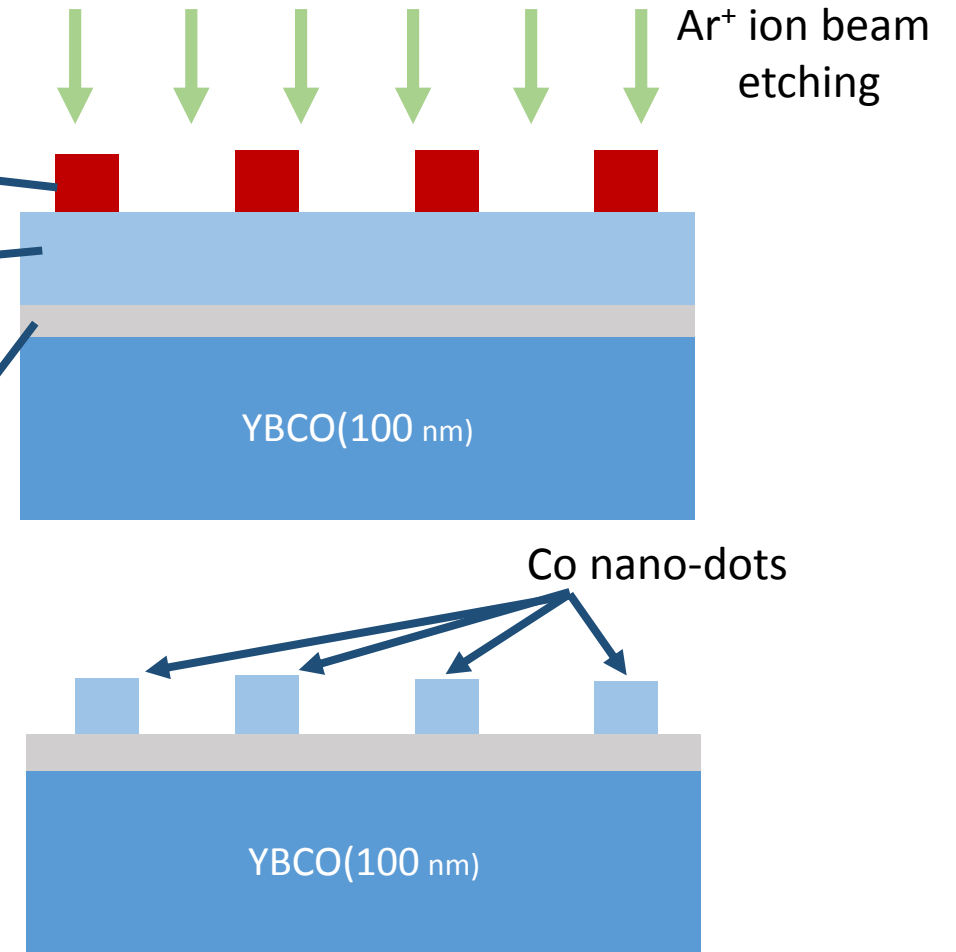
# Use of PS nano-dots for magnetic gradient generation



## 1. Cobalt thin film deposition on top of PS nano-dots



## 2. PS nano-dot as etch mask for cobalt nano-dot fabrication

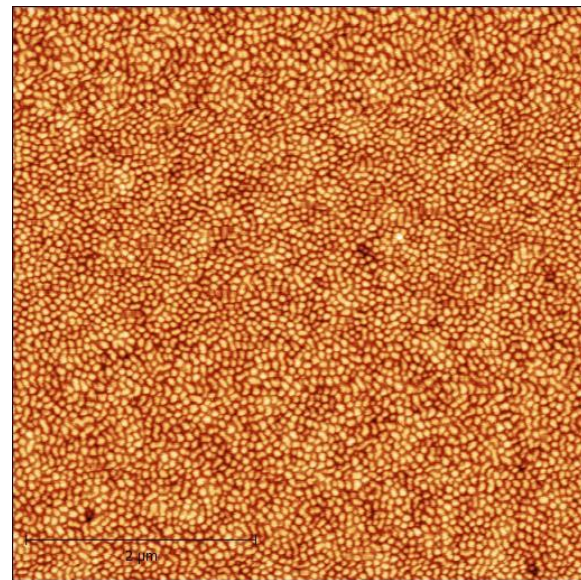
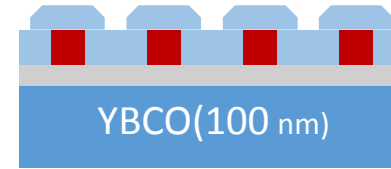


Commercially available low roughness, RMS=2 nm, YBCO layer

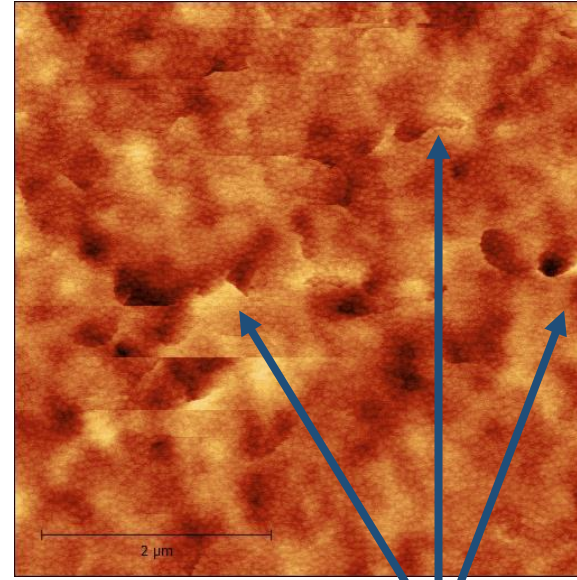
**ceraco**  
ceramic coating



## 1. Cobalt thin film deposition on top of PS nano-dots

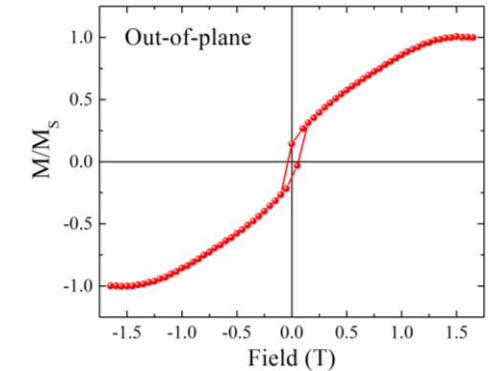
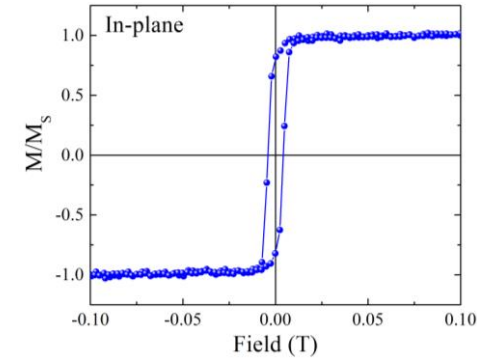


5 × 5 μm AFM image

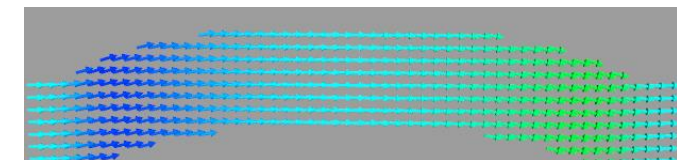


5 × 5 μm MFM image

**Domain wall contrast**



- typical film like  $M(H)$  response (in-plane magnetization, out-of-plane DW contribution)



mumax-micromagnetic simulation

- the Co thin film reproduces the PS nano-dot morphology;
- No nano-patterning signature in MFM image, just domain wall signature;
- Film-like magnetic characteristics;

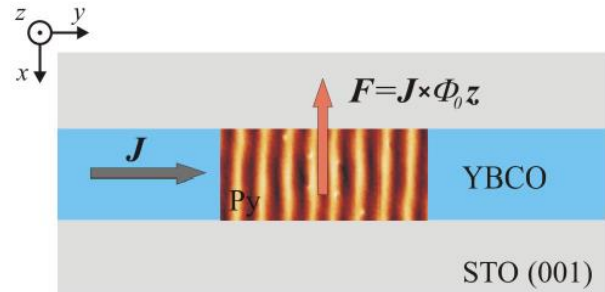
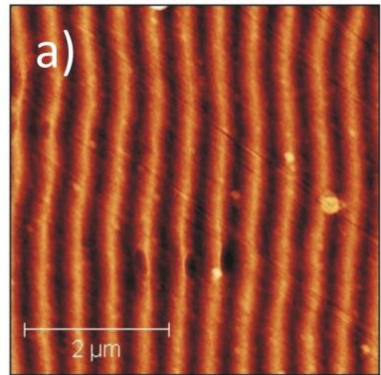
- high aspect ratio 60:5
- low out-of plane magnetization deflection

# Use of PS nano-dots for magnetic gradient generation



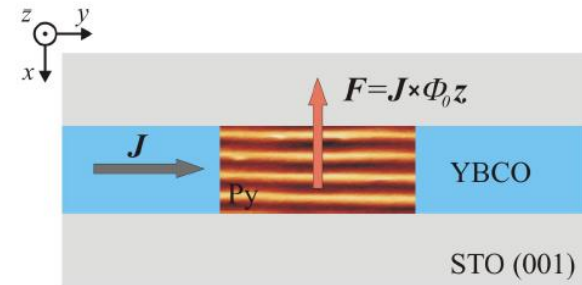
## Domain wall pinning in YBCO thin films

**Weak-stripe** domains in Permalloy (250 nm) films



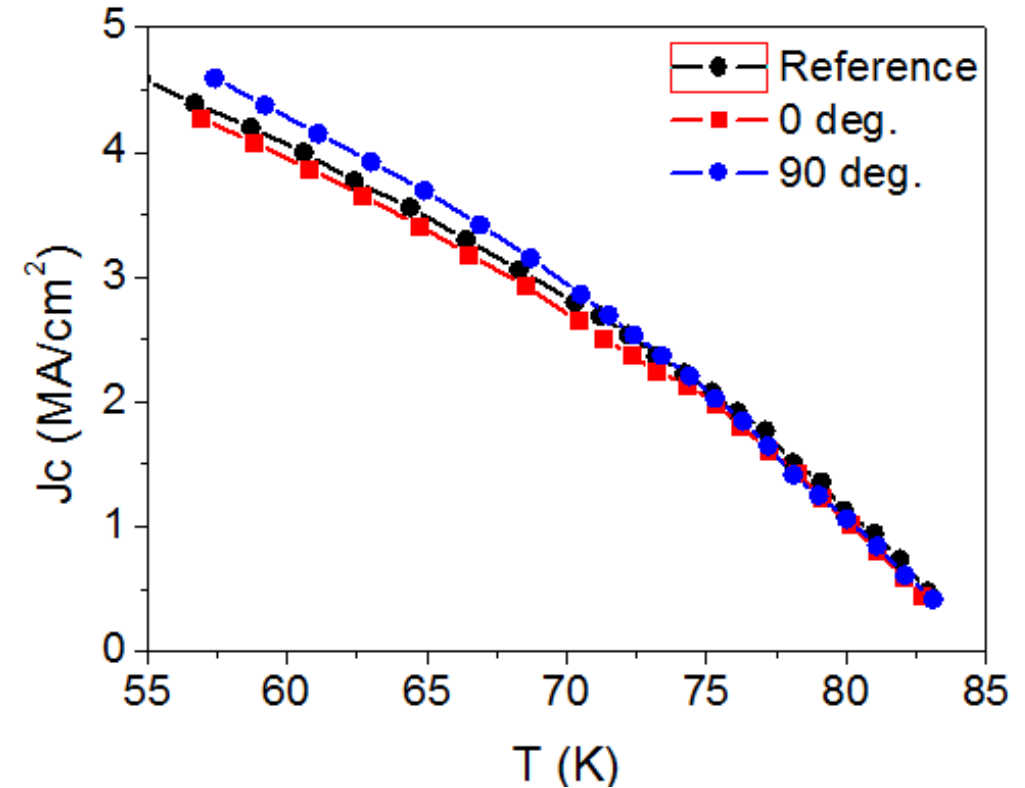
(a) 90° configuration (Vortex Guide)

No gradient



(b) 0° configuration (Vortex Pinning)

Max. gradient



No improvement of the critical current density,  $J_c$

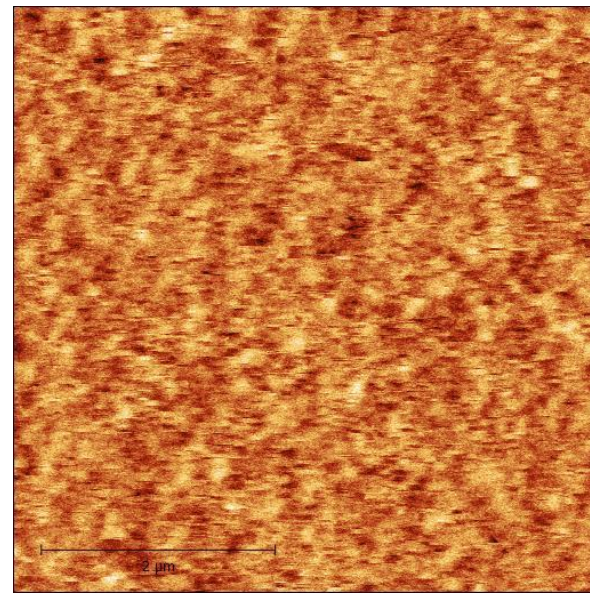
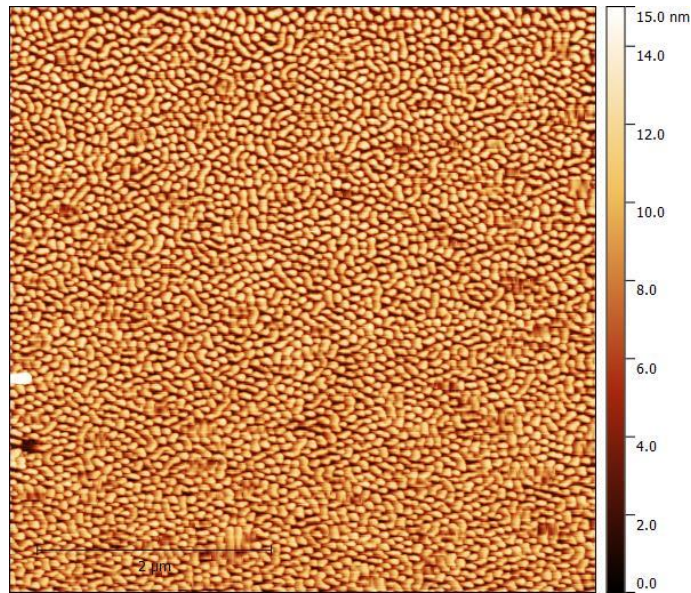
**Domain wall vortex pinning is ineffective**



# Use of PS nano-dots for magnetic gradient generation



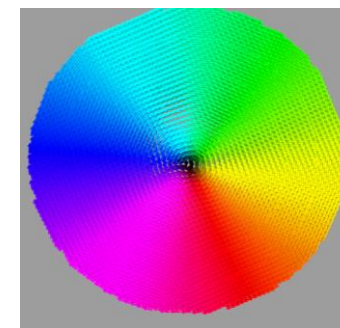
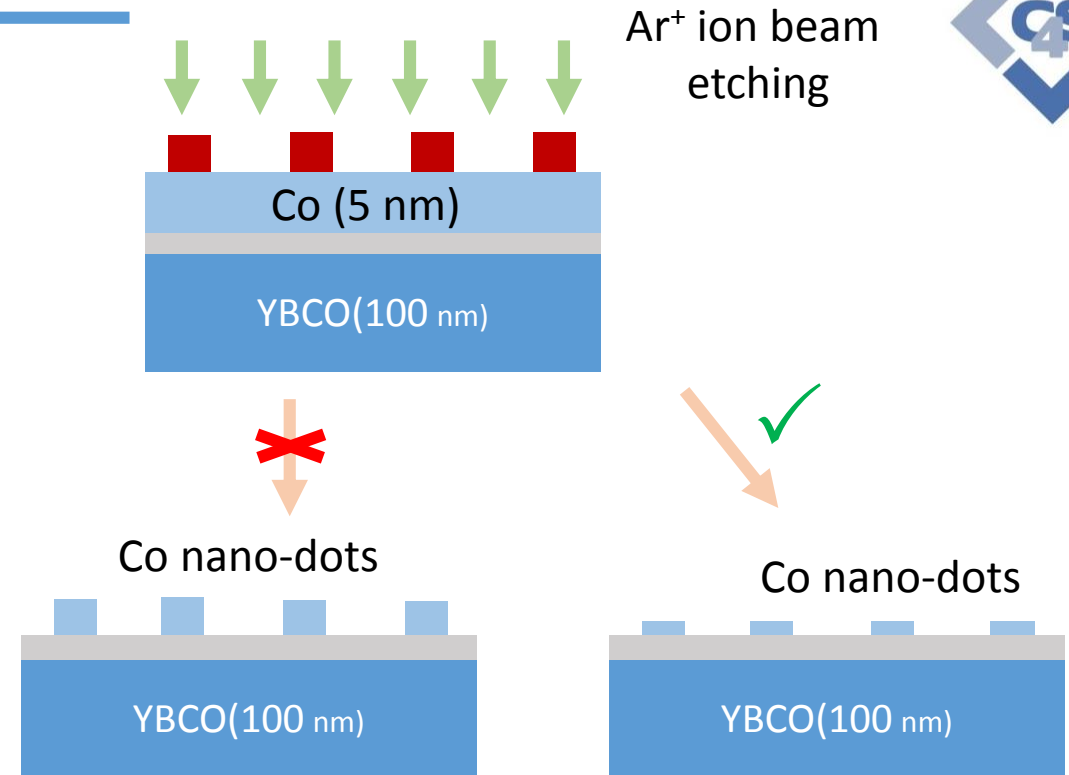
## 2. PS nano-dot as etch mask for cobalt nano-dot fabrication



5 × 5 μm AFM image

5 × 5 μm MFM image

- More localized magnetic contrast due to etching;
- **No etching selectivity** provided by the PS nano-dots;
- Etching of both Co and PS;
- Extremely high **time sensitive** process;

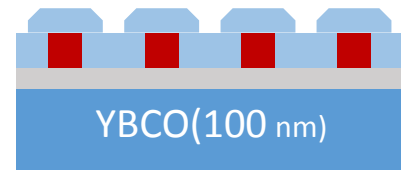


Magnetic vortex configuration  
mumax-micromagnetic simulation

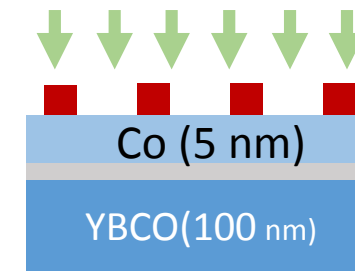
**Rapid etching of Co**  
No magnetic vortex configuration  
was observed

- Successful demonstration of uniform PS nano-dot array fabrication over large areas,  $>100 \mu\text{m}^2$ ;
- Random distribution of nano-dots was observed;
- Limited applicability of the di-block copolymer approach for strong magnetic gradient generation

High aspect ratio of PS nano-dot template



No etching selectivity of PS nano-dots



## Acknowledgements

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Thank you for  
your  
attention !

